

|    | Hits   | Search Text  |
|----|--------|--|
| 1  | 21466  | (mask or reticle) same (substrate or wafer) same align\$6                    |
| 2  | 25948  | (mask or reticle or substrate or wafer or reference or alignment) near3 mark |
| 3  | 4457   | S1 and S2  |
| 4  | 369    | (align\$6) with (numerical near aperture)                                    |
| 5  | 10603  | (lens or projection) with (numerical near aperture)                          |
| 6  | 55     | ad<="20020716" and S6  |
| 7  | 55     | S3 and S4 and S5   |
| 8  | 50     | @ad<="20020716" and S6   |
| 9  | 57299  | (align\$5 or position\$3) near4 (mirror or reflector)                        |
| 10 | 105980 | (mask or reticle) same (substrate or wafer)                                  |
| 11 | 9527   | (projection) near5 (mirror or reflector)                                     |
| 12 | 957    | S10 and S11 and S12  |
| 13 | 720    | @ad<="20020716" and S13  |
| 14 | 20184  | (alignment or reference) near2 mark  |
| 15 | 311    | S14 and S15  |
| 16 | 3509   | S15 with (mask or reticle)   |
| 17 | 5411   | S15 with (substrate or wafer)  |
| 18 | 231    | S17 and S18 and S14  |

OK  
11/4/05